

Title (en)

COATING COMPOSITION FOR ANTIREFLECTION, ANTIREFLECTION FILM AND METHOD FOR PREPARING THE SAME

Title (de)

ANTIREFLEKTIVE BESCHICHTUNGSZUSAMMENSETZUNG, ANTIREFLEXIONSFOLIE UND HERSTELLUNGSVERFAHREN DAFÜR

Title (fr)

COMPOSITION DE REVETEMENT ANTIREFLET, FILM ANTIREFLET ET PROCEDE DE PREPARATION ASSOCIE

Publication

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Application

EP 08849489 A 20081113

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- KR 20070115348 A 20071113
- KR 20070115967 A 20071114
- KR 20080035891 A 20080418

Abstract (en)

[origin: WO2009064128A2] The present invention provides a coating composition for antireflection that includes a low refractive material having a refractive index of 1.2 to 1.45 and a high refractive resin having a refractive index of 1.46 to 2, in which the difference in the surface energy between two materials is 5 mN/m or more; an antireflection film manufactured using the coating composition for antireflection; and a method of manufacturing the antireflection film. According to the present invention, the antireflection film having excellent abrasion resistance and antireflection characteristic can be manufactured using a single composition by one coating process, thereby reducing manufacturing cost.

IPC 8 full level

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Citation (search report)

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Citation (examination)

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